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	United States RNATIONAL TRADE COMMISSION
	MEMORANDUM ON PROPOSED TARIFF LEGISLATION of the 112th Congress
	Date approved July 13, 2012
I. Background	
Bill number: H.R. 4	4902
· –	John Carter
Sponsor state: TX	
Interested entity:	
-	n Photomasks, Inc.
City Round	
State TX	
Other hills on product	(112th Congress only); None
Other bills on product	(112th Congress only): None
Nature of bill: Tem	nporary duty suspension
Expiration date: Dec	ember 31, 2015
Current or previous ch	apter 99 heading: None
Retroactive date:	None
CAS number (if applica	ble): None
Industry analyst:	Mihir Torsekar
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' Tariff Affairs contact:	Jan Summers
Telephone:	202-205-2605

Note:

1. Access to an electronic copy of this memorandum is available at <u>http://www.usitc.gov/tariff_affairs/congress_reports/.</u>

2. In regard to the country(ies) of origin listed in section III, this report focuses on dutiable imports and does not take into account any tariff preference programs or special rates of duty.

II. Suggested article description(s) for enactment (including appropriate HTS subheading(s)):

Photomask blanks with synthetic quartz substrates, with zero defects greater than 0.5 microns in the photoresist and chromium or phase shift layer (provided for in subheading 3701.99.60)

(If enacted, the tariff relief provided for in this bill would be available to any entity that imports the product that is covered by the bill.)

Description above compared with bill as introduced:

Same

☑ Different (see Technical Comments section)

III. Other product information, including uses/applications and source(s) of imports

The subject photomask blanks are primarily used to create patterns for integrated circuits which, in turn, are used in electronic products such as computers and cell phones. These circuits are also known as memory chips or microprocessors. Photomask blanks are made of polished, high-purity quartz glass. The process by which photomask blanks make patterns for integrated circuits is similar to the use of "negatives" in photography. These products are mostly imported from Japan.

IV. Estimated effect on customs revenue

Subject product HTS subheading(s)	3701.99.60						
ltem	2013	2014	2015	2016	2017		
Col.1-general rate of duty (%) or percentage point reduction	3.7	3.7	3.7	3.7	3.7		
Estimated value of <i>dutiable</i> imports (\$)	20,500,000	19,500,000	18,500,000	17,600,000	16,700,000		
Customs revenue loss (\$)	758,500	721,500	684,500	651,200	617,900		

Note: Customs revenue loss is provided for 5 years, although the effective period of the proposed legislation may differ. Regarding the HTS subheading listed in the article description of the bill, the Commission may express an opinion on the HTS classification of a product to facilitate consideration of the bill. However, by law, only U.S. Customs and Border Protection is authorized to issue a binding ruling on this matter. The Commission believes that Customs should be consulted prior to enactment of the bill.

Dutiable imports were based on (more than one may apply):

Official statistics of the U.S. Department of Commerce

 \boxtimes Provided by industry sources

Industry information

⊠ Commission estimates

Duty reduction notes:

 \boxtimes This bill is not a duty reduction

This bill is a temporary duty reduction. Rates are shown below.

Col.1-general duty rate (%)

Temporary rate (%)

Percentage point reduction (%)

V. Technical comments

The phrase "either binary or phase shift" was eliminated from the article description because it was unnecessary. There are only two types of photomasks, binary and phase shift, and the description set forth above would cover both types.

VI. Continuation

VII. Contacts with domestic firms/organizations

#	Firm/organization and contact name	Telephone number	Claims same or competing product made in the United States	Submission attached	Opposition noted
1	Toppan Photomasks (Interested entity) Anthony Munguia	512-310-6574	No	No	No
2	Advanced Micro Devices, Inc. Gary Wolland	512-602-1000	No	No	No
3	Applied Materials Connie Duncan	408-563-6209	No	No	No
4	Intel Corp. Chuck Mulloy	408-765-3484	No	No	No
5	KLA-Tencor Meggan Powers	408-875-8733	No	No	No
6	Lam Research Corp. Lisa Garber	510-572-5241	No	No	No
7	Novellus Systems, Inc. Martin J. Collins	408-943-9700	No	No	No

^{112TH CONGRESS} 2D SESSION H.R.4902

To suspend temporarily the duty on photomask blanks.

IN THE HOUSE OF REPRESENTATIVES

April 26, 2012

Mr. CARTER introduced the following bill; which was referred to the Committee on Ways and Means

A BILL

To suspend temporarily the duty on photomask blanks.

- 1 Be it enacted by the Senate and House of Representa-
- 2 tives of the United States of America in Congress assembled,

3 SECTION 1. PHOTOMASK BLANKS.

- 4 (a) IN GENERAL.—Subchapter II of chapter 99 of
 5 the Harmonized Tariff Schedule of the United States is
 6 amended by inserting in numerical sequence the following
- 7 new heading:

	1	1		l	1	1	1
"	9902.01.00	Photomask blanks, either bi-					
		nary or phase shift, with syn-					
		thetic quartz substrates, with					
		zero defects greater than 0.5					
		microns in the photoresist					
		and chromium or phase shift					
		layer (provided for in sub-					
		heading 3701.99.60)	Free	No change	No change	On or before	
						12/31/2015	".

(b) EFFECTIVE DATE.—The amendment made by
 subsection (a) applies to articles entered, or withdrawn
 from warehouse for consumption, on or after the 15th day
 after the date of the enactment of this Act.